6. (Amended) A compound of the general formula II

in which T is hydrogen or a group of the formula

the residue P is hydrogen or an amine protecting group,

methoxy) ethyloxymethyl,

or a p-methoxyphenyl group, and

II

the residue R¹⁷ is hydrogen or allyl, benzyl, ethyl, methyl, 2,2,2-trichloro-tert-butyl, 2,2,2-

trichloroethyl, α-chloro-(trifluoromethyl)benzyl, 2-(p-toluenesulfonyl)ethyl, diphenyl-methyl, 2-

(trimethylsilyl)ethyl, methoxymethyl, (2-trimethyl-silyl)ethoxymethyl, benzyloxymethyl, or (2-

the residue R^{14} is a group of the formula CH_nX_{3-n} (n = 0 to 3, X = F, Cl, Br, I), a phenyl group,

B', E, the residues R^1 and R^2 , and R^{15} and R^{16} have the meanings stated in claim 1.

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9. (Twice Amended) A process for the production of a compound as defined in claim 1, wherein compounds of the general formula II

in which T is hydrogen or a group of the formula

the residue P is hydrogen or an amme protecting group,

or
$$R^{15}$$
 C C R^{16}

the residue R^{17} is hydrogen or allyl, benzyl, ethyl, methyl, 2,2,2-trichloro-tert-butyl, 2,2,2-trichloroethyl, α -chloro-(trifluoromethyl)benzyl, 2-(p-toluenesulfonyl)ethyl, diphenyl-methyl, 2-(trimethylsilyl)ethyl, methoxymethyl, (2-trimethyl-silyl)ethoxymethyl, benzyloxymethyl, or (2-methoxy)ethyloxymethyl,

the residue R^{14} is a group of the formula CH_nX_{3-n} (n = 0 to 3, X = F, Cl, Br, I), a phenyl group, or a p-methoxyphenyl group, and

B', E, the residue R¹ and R², and R¹⁵ and R¹⁶ have the meanings stated in claim 1 are converted in known matter.